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3,3 kV Full SiC in LV100 Package

6,5 kV Full SiC in HV100 Package

Gaining Speed Mitsubishi Electric SiC Power Modules



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Gaining Speed: Mitsubishi Electric SiC-Power Modules

In "Bodo's Power System", Sept 2017 edition, we published an overview about the history and status of our SiC-Power modules covering a wide range of commercially available SiC-modules from several ten amps up to 1200 A and rated voltages from 600V to 3300V [1]. Today, one year later, the SiC technology has gained further speed. The present article is giving a survey about Mitsubishi Electric's latest achievements on SiC power modules with regard to research, product development and applications. Special focus of this article is on high voltage SiC-modules.

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SiC Research in Japan

The research activities on SiC are coordinated in Japan by an organization called NEDO (New Energy and Industrial Development Organization). NEDO is Japan's largest public R&D management organization for coordinating the innovation efforts in strategic directions. The development of high power density and high withstand voltage SiC power modules is one of NEDO's main R&D directions and Mitsubishi Electric is a key player in this activity [2]. Several outstanding Mitsubishi Electric R&D results on SiC technology reported in this article have been supported by NEDO.

Embedding the Schottky-Barrier-Diode (SBD) into the SiC-MOS-FET

The idea of embedding the SBD directly into the MOSFET-chip is shown in Figure 1 [3].



Figure 1: Cross section of (a) conventional SiC-MOSFET with external SBD and (b) an SBD-embedded SiC-MOSFET

As body diode operation may cause bipolar degradation by expansion of stacking faults in the SiC-MOSFET it is recommended to be avoided. Both cross sectional structures shown in Figure 1 are achieving this objective by the same principle: As long as the forward voltage of SBD is lower than the built-in potential Vpn of the MOSFET's body diode there will be no current flowing through the bipolar body diode. Many SiC-modules available today [1] are using the approach (a). The research results reported in [3] show that by integrating the SBD into the MOSFET-chip (b) the condition "no bipolar body diode current flow" is achievable for remarkably higher SBD current densities than in the conventional structure (a) with external antiparallel SBD. Consequently, the active chip area needed for forming a functional switch (MOSFET + antiparallel diode) can be drastically reduced by using the approach (b).



Figure 2: Active area of 3.3kV and 6.5kV conventional SiC-MOSFET with external SBD compared with SBD-embedded SiC-MOSFET [4]



Figure 3: Specific on-resistances separated into channel resistance (red), drift resistance (green) and spread resistance (blue) in the 3.3kV and 6.5kV SBD-embedded SiC-MOSFETs at Tj=150°C compared to those in conventional SiC-MOSFETs [4]

In [4] the impact of embedding the Schottky-Barrier Diode into the SiC-MOSFET-chip is investigated for 3.3kV and 6.5kV SiC-MOSFETs. The reduction rate of active chip area is 50% for 3.3kV SiC-modules and 75% (!) for 6.5kV-modules, see Figure 2. This example is showing that the approach (b) is attractive especially for very high voltage SiC-MOSFETs. On the other hand, the impact of integrating the SBD into the MOSFET on increasing (worsening) the specific on-resistance is small as shown Figure 3. The forward characteristics of new SBD-embedded SiC-MOSFET samples are shown in Figure 4.



Figure 4: Drain characteristics of the 3.3kV and 6.5kV samples at room temperature and Tj=150°C [4]

New 6.5kV Full-SiC Dual Module

Based on the new 6.5kV SiC-MOSFETs with embedded SBD the Mitsubishi Electric Advanced Technology R&D Center announced in January 2018 [5] the world's highest power density Full-SiC-Module representing 9.3kVA/cm³, see Figure 5. When comparing this power density with 5.1kVA/cm³ offered by best in class conventional 6.5kV Si-Power module the big potential for system size reduction becomes evident.



Figure 5: Prototype of 6.5kV Full-SiC Power Semiconductor Module

The performance of the new 6.5kV Full-SiC dual module is investigated in [6] under different aspects. Based on the recently developed new HV100 standard dual package [7], the internal module structure was optimized by 3D electromagnetic simulation for reducing the internal package inductance, for achieving a good dynamic current sharing among the paralleled SiC-MOSFET chips and for improving the EMI-robustness. Special attention was paid to eliminate the magnetic interference toward the gate caused by the high speed switching. The simulated turn-on waveforms before and after optimization are shown in Figure 6. The measured turn-on waveform at room temperature and Tj=175°C in Fig.7 show that switching speed at P- an N-side are almost the same. Furthermore no significant differences in switching performance can be seen between room temperature and Tj=175°, indicating that the device performance is unipolar.



Figure 6: Simulated turn-on waveforms before and after optimization





Figure 7: Comparison of turn-on waveforms of P- and N-side at (a) room temperature and (b) Tj=175°C

The total switching energy of new SBD-embedded 6.5kV Full-SiC-MOSFET Module is less than 10% compared to conventional 6.5kV Si-IGBT Modules, see Figure 8.



Figure 8: Comparison of switching loss between Si-IGBT at Tj150°C, SiC-MOSFET and SBD-embedded SiCMOSFET at 175°C

This drastic switching loss reduction is opening the door to high voltage power module applications with switching frequencies in the range of several kHz, where the today's 6.5kV Si-HVIGBT-modules were found to be not really applicable, even when used in resonant mode (for example in solid state transformer applications). As reference, the power loss simulation shown in Figure 9 at 500Hz, 2kHz and 10kHz is provided in [6].







Figure 10: Trade-off between on-resistance and short circuit time tsc

Improving the short circuit capability of SiC-MOSFET

One of the issues with today's SiC-MOSFETs is their limited short circuit endurance. One way to increase the allowable short circuit time tsc would be to increase the on-resistance of the SiC-MOSFET. But this approach would lead to large on-state energy loss. The principle trade-off relationship between on-resistance and short circuit time tsc is explained in Figure 10.

In [8] and [9] Mitsubishi Electric announced a new proprietary chip structure that is currently in R&D status to tackle this issue: by introducing an additional region into the source area, see Figure 11. By this means, the source series resistance of the SiC-MOSFET is controlled and the incidence of excessive current flow during short circuit operation is reduced.



Figure 11: Cross-sectional view of the newly developed SiC-MOSFET [9]

By this approach, a short circuit time tsc=8µs (similar to today's Si-IGBT) is achievable without increasing the on-resistance significantly. According to Mitsubishi Electric's press release dated September 2017 this new SiC-device is offering the world's highest power efficiency rating of any 1200V-class power devices with a short–circuit time exceeding 8µs [9]. In Figure 12 the on-state resistance versus short-circuit time of new SiC-MOSFET is compared with conventional SiC-MOSFET. At tsc=8µs the specific on-resistance has been reduced by 40% compared to conventional SiC-MOSFET.



Figure 12: Specific on-resistance at room temperature versus shortcircuit time

Simulation of SiC-MOSFET switching behaviour

Accurate simulation of transient switching behavior, for example of the drain-source voltage slope dvDS/dt and the drain current slope diD/ dt is important for optimizing the internal structure of SiC-MOSFET-modules. In [10] a new behavioral SiC-MOSFET model is described

taking into account the internal stray inductances and capacitances. By using this model, it was possible to reproduce accurately the operation of paralleled SiC-MOSFETs even under thermally imbalanced conditions [11]. In [12] this model is further refined. The waveforms shown Figure 13 are indicating a good matching of simulated and experimental results. The new SiC-MOSFET model is a powerful tool for simulation-based design of power electronic circuits [12].



Figure 13: Comparison of simulated and experimental waveforms of a 15A/1200V SiC-MOSFET during (a) turn-on and (b) turn-off

New 750A/3300V Full SiC Dual Module

The Mitsubishi Electric 750A/3300V Full-SiC Dual Module was announced at PCIM-Europe 2017 Conference [13]. Meanwhile this device is commercially available; the type name is FMF750DC-66A. For minimizing the internal package inductances and for good current balancing among the paralleled chips the most advanced dual package for this voltage and power class, the new LV100 package, has been employed, see Figure 14.



Figure 14: FMF750DC-66A package outline

The two principle options for system performance improvements with FMF750DC-66A versus conventional HVIGBT-modules are [14]:

A) Increasing the switching frequency by keeping the same (for the same cooling system) power loss level as with today's Si-IGBTs. This direction is interesting for obtaining system benefits that were not reachable with today's Si-HVIGBT-Modules due to their higher switching energy Esw. The simulation results reported in [14] are indicating that a same inverter output current level the switching frequency can be increased by a factor of 5...7 when using the FMF750DC-66A instead of its Si-HVIGBT counterpart.

- B) Reducing the power loss (increasing the system efficiency) for reducing the cooling efforts by maintaining the switching frequency at similar level as with today's HVIGBTs with the objective of:
 - B1) increasing the system's power density (reducing the system size & weight);
 - B2) increasing the system efficiency for increasing the operation time of autonomous, battery driven systems or for reducing the TCO caused by energy loss in permanently operating power conversion systems (for ex. UPS or PV-inverters).

Depending on the application requirements, also a mixture of both potential performance improvement options A) and B) is possible.

When designing a power electronic system with Full-SiC Modules the question arises how to handle their higher switching speed compared with Si-IGBTs, especially their higher dvDS/dt. In [15] the influences of temperature, gate resistance and gate voltage on the switching performance of new FMF750DC-66A have been studied. In Figure 15 the turn-off waveforms for different gate resistors are given. The Fig.16 is showing the dependency of dvDS/dt on gate condition. The measured trade-off curves Eoff vs. dvDS/dt are shown in Figure 17.



Figure 15: Voltage transients during turn-off for different gate resistances (VDD=1800V, ID=750A, Tj=25°C, $RG(off) = 0.9...6.2\Omega$)



Figure 16: Voltage slope during turn-on and turn-off for different gate resistances RG and gate voltages VGS (VDD=1800V, ID=750A, $Tj=25^{\circ}$ C, RG(off) = 0.9...6.2 Ω)

As conclusion of the experimental investigations in [15] a good controllability of FMF750DC-66A voltage transients by the gate drive conditions was confirmed.



Figure 17: Turn-off losses of FMF750DC-66A in dependency on dvDS/dt

Application examples of High Power SiC modules in Japan During last International Power Electronics Conference in May 2018

(IPEC'18, Niigata, Japan) several application examples in Japan with Mitsubishi Electric SiC-Power Modules were reported:

By using 1200A/1700V hybrid SiC-modules in a 600VDC tramcar the traction converter size was reduced by 40% compared to Si-IGBT system [16].

By using 3300V full SiC-Modules in a Modular Multilevel Converter for HVDC-transmission the following results have been achieved [17]: loss reduction by 50%; size reduction by 21% and weight reduction by 14% compared to the solution with conventional Si-HVIGBT-modules.

By using SiC-Modules instead of IGBT-Modules in a 750kW PV-inverter a maximum efficiency of 99% was reported [18], which is about 0,4% better than with conventional Si-IGBT.

Conclusion

During the past year, Mitsubishi Electric has reported several outstanding achievements in high voltage SiC technology. A new 750A/3300V full SiC dual Module FMF750DC-66A was made commercially available. By embedding the antiparallel Schottky-Diode directly into the SiC-MOSFET chip it was possible to reduce the active chip area needed for 6.5kV-full SiC modules by 75% (!). By using this new SBD-embedded MOSFET chips a 6.5kV full SiC module was presented with the world's highest power density of 9.3kVA/ cm³. Outstanding application benefits when using 1700V and 3300V SiC-Modules have been reported from several end-users in Japan indicating that the introduction of SiC-technology is gaining speed particularly for high voltage applications. By the reported over the past year innovations, Mitsubishi Electric has proven its technology leadership for HV-SiC-modules.

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